

Preparation of Porous Silicon Photodetector Enhanced by Ag Nanoparticle to Protect Medical Personnel

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Abstract

This work investigation the effect of Ag nanoparticle to improvement the sensitivity of photodetector. Porous silicon prepared with photoelectrochemical etching by using n-type silicon substrate. To increase the efficiency of detection deposited the Ag nanoparticle on porous silicon surface by annealing process. SEM and AFM technique were used to study the morphological characteristics of the PSi surface. Dark and photo current-voltage and responsivity were probed before and after the deposit Ag nanoparticle and the responsivity increased from 0.35A/W to 0.6A/W and the responsivity increased in infrared region.

Keywords: Porous silicon . Annealing . Depositing . Ag nanoparticles

Introduction

The latest notice of powerful visible photoluminescence in anodically etched porous silicon has created substantial attention 1. Very easy factors demonstrate that two assumptions are needed for effective emission of visible light from silicon components: (I) a confinement of providers into nanometer-sized silicon cells in purchase to bring sufficient confinement to take optical transitions in the visible array; (II) an improvement of the light quantum effectiveness, which can bring its source from an enhance in the radiative recombination rate considering of the busting of energy conservation or from a reducing of the nonradiative works by a passivation of the limited region surfaces 2 these advantage are suitable for building photodetector. Newly optical properties have been aimed for detection, admitting variant of PL, reflectivity and optical wave guiding. Optical detectors are predicting because of their very quick response 3. The porous silicon photodetectors produced by traditional methods are limited in efficiency due to the lack of stability in electrical and optical properties, deficient dark current

and deficient photo current deficient light sensitivity, so the scope of application is limited 4. The porous silicon photodetector manufactured by RTO process are widely used as optical devices because of their high quality in sensitivity of light. The accelerate of a PSi photodetector is significant figure of merit 5 . There are three basic types of porous silicon photodetectors such like metal semiconductor metal, p-n junction and shottky diode were manufactured to detect light 6. The human eye is sensitive to all of the radiation in the electromagnetic spectrum and this radiation when with high intensity can damage the lens and cornea of the eye and can also damage the skin and tissues 7. In 2005, A.M.rossi et al. reported the improvement of porous silicon photodetector by using rapid thermal oxidation RTO process at 850 C where the responsivity was around 2.5 A/W and raised to 5.5 A/W at 800 nm 8. Eshawer T. et al in 2013 observed reduced reflection losses and improved absorption of light in visible region after depositing Ag nanoparticles on silicon substrate 9. In this research, used Ag nanoparticle film instead of RTO process where the responsivity is improvement after depositing on porous silicon.

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Materials and Method

The Porous silicon for this study created by photoelectrochemical etching on n-type (100) silicon wafers (1-3 Ωcm). The anodization current density was

12 mAcm⁻² had a porosity equal to 70% and using a Teflon cell with an electrolyte containing HF: Ethanol (2:1). For photoelectrochemical etching using a laser with the wavelength 560 nm. The morphological study of porous silicon was started by SEM and AFM before and after adding Ag nanoparticle. The Porosity of the porous silicon, as determined gravimetrically, was 60%.

To enhance the electrical properties was made on back surface by depositing Aluminum with a thickness 100 nm by annealing under a vacuum at 350 C for 20 min. The electrical properties (dark and illuminated I-V) of photodetector were studied in laboratories temperature by using electro meter and two light intensity. The deposited silver film were afterward annealed at 450 C for 45 min. in Nitrogen situation to alter the surface structure. The thickness of Ag thin film was 100 nm where this thickness was suitable for this photodetector. The structures of this detector content of Ag/PSi/Si/Al materials.

Results and Discussion

The SEM images of the silicon pore layer show a coarse surface structure with a number of nanosized pores as shown in Figure 1. The Pores contain cylindrical and rectangular shapes that are randomly distributed, vertically perpendicular to the sample level where the porous diameters range from 0.3 to 1.5 μm. The increase in pore diameter is due to increase in the number of holes on silicon surface when the laser light is absorbed by the upper layer of silicon.

The SEM images showed some variation in porous silicon morphology before and after the deposition of silver particles. Figure 2 shows SEM image of Ag films deposited on porous silicon by annealing at 450 C for 45 min. in vacuum environment. The deposited nanoparticles were in the form of small sizes distributed on top and also with large nanoparticles size. The nanoparticles fill holes located on porous silicon surface where the image of the electron microscope shows how these holes are filled. The AFM images of the porous silicon layer after addition of Nanoparticles for silver are shown in the figure 3, where a change in silicon surface is observed in after adding silver particles where the boundaries of the pores were clear and the thickness of the wall of the pores increased also after the addition of these nanoparticles. The figure (4) shows the behavior of the dark current before and after the addition of silver

nanoparticles in the forward and reverse bias where the structure (Ag/PSi/Si/Al) possesses Ag/PSi Schottky and Si/Al heterojunction. The addition of silver particles to the porous silicon surface causes an increase in the forward current and reduces the resistance of porous silicon layer and the reverse current decreases after the addition. Another important way to determine the electrical properties of PS is current measurements under lighting. Figure(5) display the IPH-V characteristics of porous silicon as a photodetector after illuminated under light intensity before and after adding Ag nanoparticles, where the increase in current from (0.8) to (1.6mA) at 2V is observed compared to before adding silver nanoparticles This improvement can be attributed to increased absorption in the surface of the porous and also short the length of diffusion of photogenerated carriers, As well as by increasing photoreceptors carrier from silver particles to porous silicon. The photo responsivity of PSi before and after adding Ag nanoparticle are shown in Figure(6). Where the response was between 400 and 1000nm in wavelengths. The maximum photoresponse was 0.6A/W in 695 nm due to raising absorption of light by Ag nanoparticle where the responsivity after Adding Ag nanoparticle was better than from fresh PSi. So the region between 700nm to 1000 nm is a infrared raddiation and maximum photoresponse in infrared region was 0.38 A/W in 810 nm.

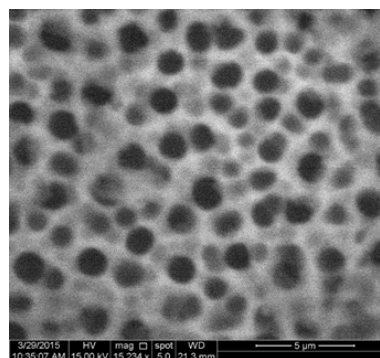


Figure 1: SEM image for fresh PSi.

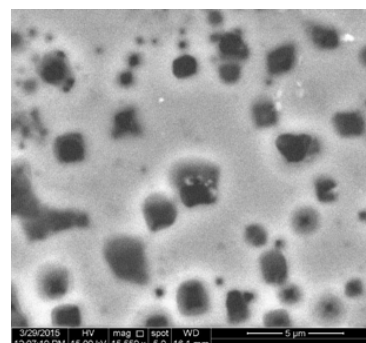


Figure 2: SEM image after adding Ag nanoparticle

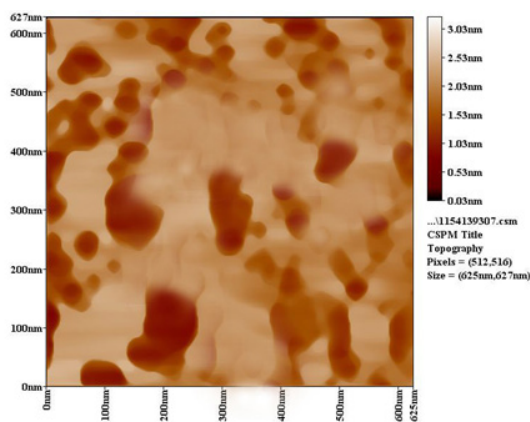


Figure 3. 2D AFM image a) fresh porous silicon b) after adding Ag nanoparticle

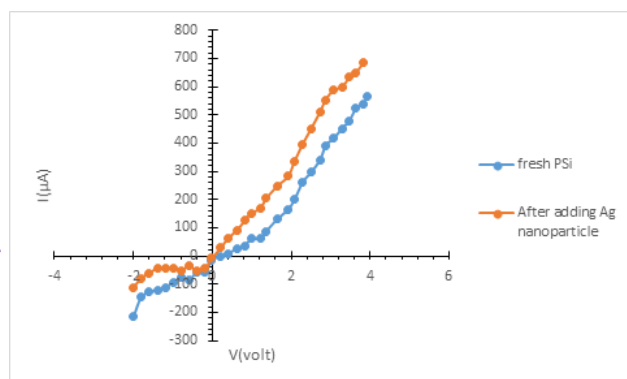


Figure 4: behavior of I-V characteristics before and after adding Ag nanoparticle in dark

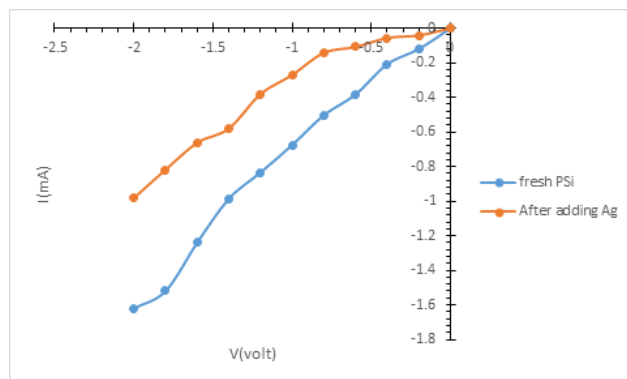


Figure 5: behavior of I-V characteristics before and after depositing Ag nanoparticle in illumination

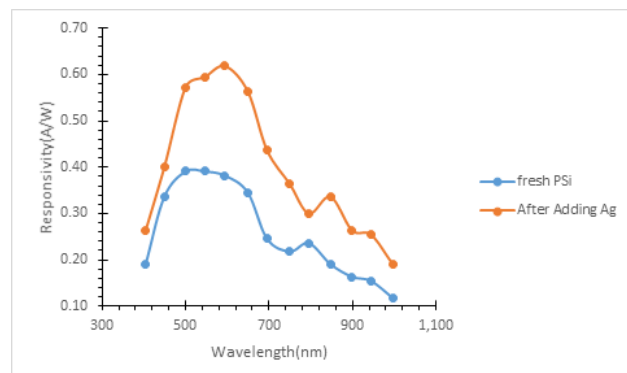


Figure 6: Responsivity before and after adding Ag

nanoparticle

Conclusion

In this work, we prepared a photodetector with low dark current in reverse bias by depositing Ag nanoparticle and with increasing in photocurrent after depositing by annealing process, where the photocurrent increased from (0.8) to (1.8mA) at 2V. The responsivity was also enhanced after Ag nanoparticle deposited and we get the best response in (0.6 A/W) under light illumination and 0.38 A/W in infrared region.

Financial Disclosure: There is no financial disclosure.

Conflict of Interest: None to declare.

Ethical Clearance: All experimental protocols were approved under the Department of medical science, College of nursing, Misan University, Iraq and all experiments were carried out in accordance with approved guidelines.

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